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(71) Applicant (for all designated States except US): TOKYO
OHKA KOGYO CO., LTD. [JP/JP]; 150, Nakamaruko,
Nakahara-ku, Kawasaki-shi, Kanagawa, 2110012 (JP).

(72) Inventors; and

(75) Inventors/Applicants (for US only): MASUDA, Yasuo
[JP/JP]; c/o Tokyo Ohka Kogyo Co., Ltd., 150, Naka-
maruko, Nakahara-ku, Kawasaki-shi, Kanagawa, 2110012
(JP). OKUI, Toshiki [JP/JP]; c/o Tokyo Ohka Kogyo
Co., Ltd., 150, Nakamaruko, Nakahara-ku, Kawasaki-shi,
Kanagawa, 2110012 (JP).

(74) Agents: TANAI, Sumio et al.; 2-3-1, Yaesu, Chuo-ku,
Tokyo 104-8453 (JP).

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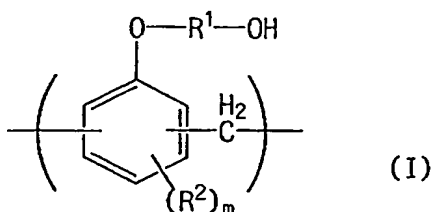
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(54) Title: POSITIVE PHOTORESIST COMPOSITION AND METHOD OF FORMING RESIST PATTERN



(57) Abstract: A positive photoresist composition comprising an alkali-solu-
ble novolak resin (A) containing a structural unit (a1) represented by a general
formula (I) shown below, and a structural unit (a2) represented by a general
formula (II) shown below, and a photosensitizer (B).

